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## BIB DATA SHEET

CONFIRMATION NO. 6408

SERIAL NUMBER	FILING or 371(c) DATE	CLASS	GROUP ART UNIT	ATTORNEY DOCKET NO.		
10/550,853	09/22/2005	438	2823	NL03 0357 US1		
<b>RULE</b>						
<b>APPLICANTS</b> Philippe Meunier-Beillard, Eindhoven, NETHERLANDS; Mathieu Rosa Jozef Caymax, Leuven, BELGIUM; <b>** CONTINUING DATA *****</b> Yes /KN/ This application is a 371 of PCT/IB04/50333 03/25/2004 <b>** FOREIGN APPLICATIONS *****</b> Yes /KN/ EUROPEAN PATENT OFFICE (EPO) 03100821.2 03/28/2003 <b>** IF REQUIRED, FOREIGN FILING LICENSE GRANTED **</b> 06/04/2006						
Foreign Priority claimed <input checked="" type="checkbox"/> Yes <input type="checkbox"/> No 35 USC 119(a-d) conditions met <input checked="" type="checkbox"/> Yes <input type="checkbox"/> No Verified and /KHIEM D NGUYEN/ Acknowledged Examiner's Signature		<input type="checkbox"/> Met after Allowance /KN/ Initials	<b>STATE OR COUNTRY</b> NETHERLANDS	<b>SHEETS DRAWINGS</b> 6	<b>TOTAL CLAIMS</b> 20 <u>17</u>	<b>INDEPENDENT CLAIMS</b> 2 <u>1</u>
<b>ADDRESS</b> NXP, B.V. NXP INTELLECTUAL PROPERTY & LICENSING M/S41-SJ 1109 MCKAY DRIVE SAN JOSE, CA 95131 UNITED STATES						
<b>TITLE</b> Method of epitaxial deposition of an n-doped silicon layer						
<b>FILING FEE RECEIVED</b> 900	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:			<input type="checkbox"/> All Fees <input type="checkbox"/> 1.16 Fees (Filing) <input type="checkbox"/> 1.17 Fees (Processing Ext. of time) <input type="checkbox"/> 1.18 Fees (Issue) <input type="checkbox"/> Other _____ <input type="checkbox"/> Credit		